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FIG. 1A

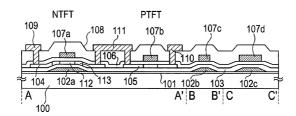


FIG. 1B

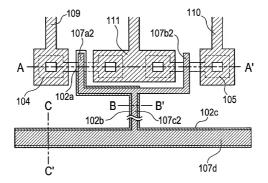


FIG. 2A

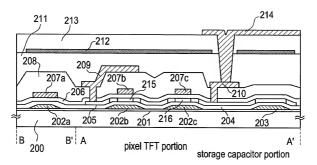
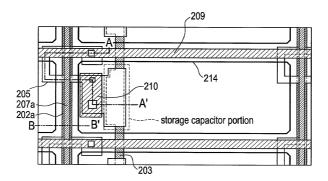
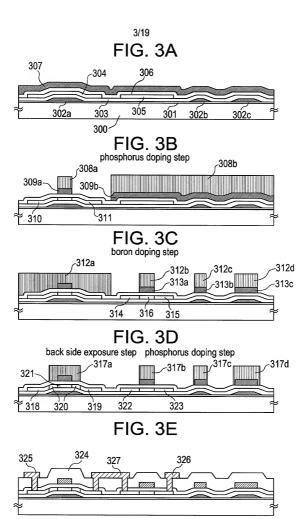


FIG. 2B





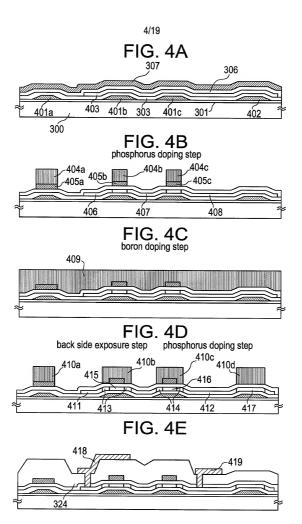


FIG. 5A

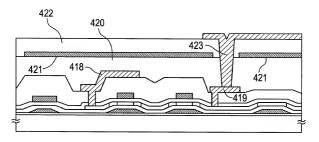


FIG. 5B

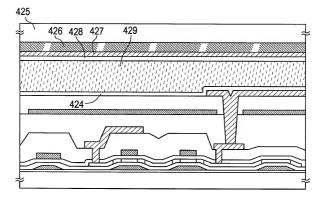


FIG. 6

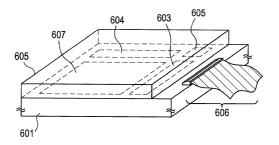


FIG. 7

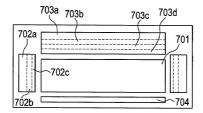


FIG. 8A

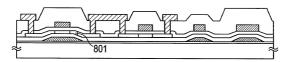


FIG. 8B

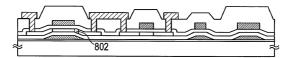


FIG. 8C

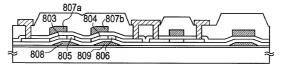


FIG. 8D

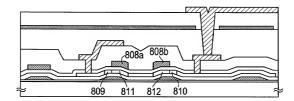


FIG. 9A

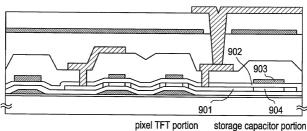
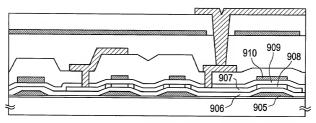


FIG. 9B



pixel TFT portion

storage capacitor portion

FIG. 10A

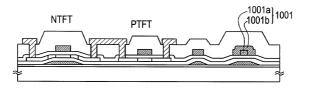
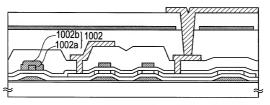


FIG. 10B



pixel TFT portion storage capacitor portion

FIG. 11A

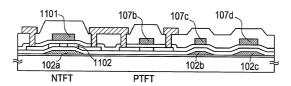


FIG. 11B

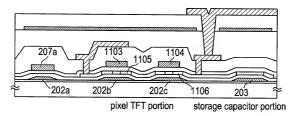


FIG. 12 gettering step by phosphorus

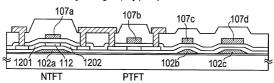


FIG. 13A

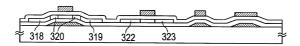


FIG. 13B

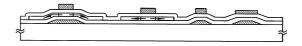
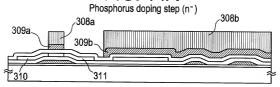


FIG. 14A



 $FIG.\ 14B$ Backside exposure step, phosphorus doping step (n $\)$

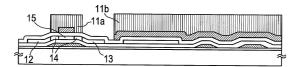


FIG. 14C Boron doping step (p⁺⁺)

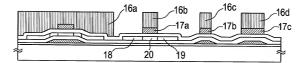


FIG. 15A

Boron doping step (p++)

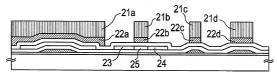
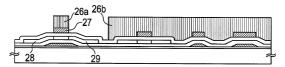


FIG. 15B
Phosphorus doping step (n⁻)



 $\begin{tabular}{ll} FIG.~15C \\ Backside~exposure~step,~phosphorus~doping~step~(n^+) \\ \end{tabular}$

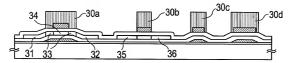


FIG. 16A

Boron doping step (p++)

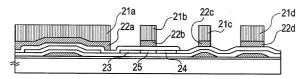


FIG. 16B

Phosphorus doping step (n++)

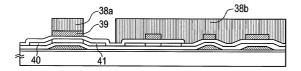


FIG. 16C

Phosphorus doping step (n-)

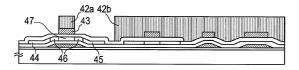


FIG. 17A

Phosphorus doping step (n+)

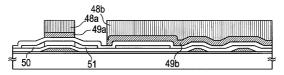


FIG. 17B

Phosphorus doping step (n-)

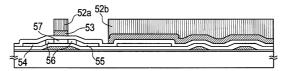


FIG. 17C

Boron doping step (n++)

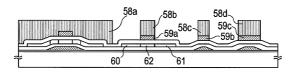


FIG. 18A
Phosphorus doping step (n+)

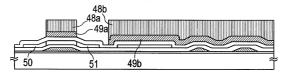


FIG. 18B Boron doping step (p++)

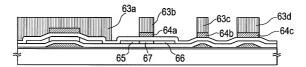


FIG. 18C

Phosphorus doping step (n⁻)

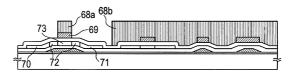


FIG. 19A

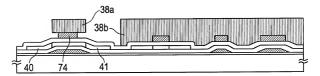


FIG. 19B

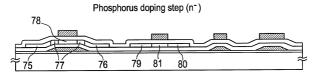


FIG. 20A

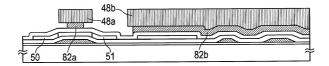


FIG. 20B

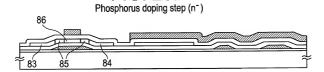


FIG. 21A

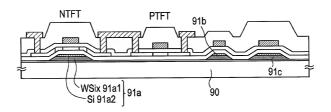
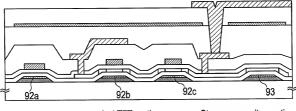


FIG. 21B



pixel TFT portion

Storage capacitor portion

